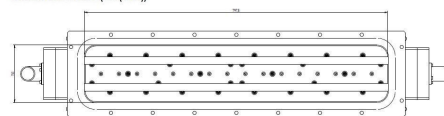


# PLASMA ARRAY (LARGE AREA) - MA6000Y-023BC

**Categories:** Plasma components

Outline Dimensions (mm(inch))



## BESCHREIBUNG

A combination of duo-plasmalines can be used to obtain a two dimensional plasma array. Single sources as well as 2, 4 and 8 parallel arranged plasmalines are available for plasma assisted surface treatment like surface activating, etching and deposition.

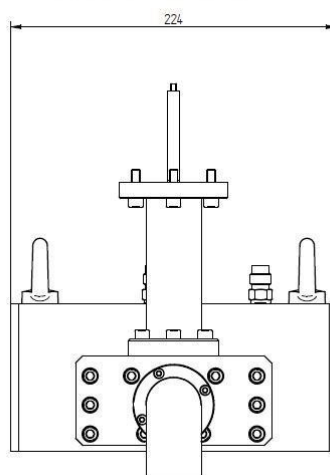
- Low pressure microwave plasma source
- Suitable for cleaning, etching, ashing, deposition, sterilization, pretreatment
- Compact design
- Easy adaption to customer systems
- Integrated gas shower
- High plasma density
- High efficiency

## BILDERGALERIE

Outline Dimensions (mm(inch))



Outline Dimensions (mm(inch))



## ADDITIONAL INFORMATION

<b>Typ</b>	Plasma array (large area)
<b>Process</b>	Etching & Deposition
<b>Output Connection Type</b>	Plasma area 797,5 mm x 150 mm
<b>Dielectric material</b>	Ceramics
<b>Output Power [W]</b>	2x 3000
<b>Frequency [MHz]</b>	2450
<b>Gas manifold</b>	Double